



LOR B series resists

Product	LOR B series resists
Manufacturer	MicroChem Corp.
Composition	65–90% cyclopentanone , 10–15% 1-methoxy-2-propanol , 1–20% polyaliphatic imide copolymer , 0.1–2% Proprietary Dye B; liquid
Synonyms	LOR
Typical Uses	Photolithography for lift-off processes
Hazards	<div>   </div> <p>203</p> <p>Skin corrosion/irritation CATEGORY 2, Serious eye damage/eye irritation CATEGORY 2A, Flammable liquids CATEGORY 3, Specific target organ toxicity – single exposure CATEGORY 3, Acute toxicity CATEGORY 4</p>
Storage	Cabinet 11 (flammables cabinet in Wet Aisle 1)
Disposal	Solid: Organic waste / organic sharps waste containers in primary or secondary litho areas. Liquid: solvent waste bottles in litho wet decks or wet decks 1A/1B/2A.
Comments	LOR 5B is generally used with AZ 1512 for a lift-off bilayer process . May be used in Spin-Bake Stations #1/#2. Use EBR PG to clean spinner after use.
Status	STOCKED



Check First

Please contact a nanoFAB staff member for uses not listed above.

Data sheet

- [LOR and PGMI resists \(Kayaku\)](#)